

3.4 - Drift of Carriers in Electric and Magnetic Fields

Conductivity & Mobility

- Charge carriers in a solid are in constant motion, even at thermal equilibrium
 - ↳ At room temp eg ... thermal motion of an individual electron is visualised as random scattering from lattice vibrations, other electrons & defects.



}

- ↳ Since scattering is random
- No net motion of the (groups) of electrons/cm³ over any period of time

→ The probability of the electron in the figure above returning to its starting point after some time (t) is negligible small.

HOWEVER:
eg n-type (10^{16} cm^{-3} electrons), there will be no preferred direction of motion for the group of electrons ∴ no net current flow.

- If electric field (E_x) is applied in the x-direction

+ E_x - } $F_x = -qE_x$ → May be insufficient to alter the random path of an individual electron.
 ↓ ↓ ↓ ↓ } # BUT: when the effect is averaged over all electrons is a net motion of the group in the (-x direction)

∴ The force on the field on the n electrons $/\text{cm}^3$ is:

$$-nqE_x = \frac{dp_x}{dt} \Big|_{\text{field}}$$

where p_x is the total momentum of the group

↳ This indicates continuous acceleration of the electron → NOT THE CASE ⚡ because the net acceleration is balanced by the deceleration of the ⚡ collision process.

- While the steady field E_x produces a net momentum P_{-x}
The rate of change of momentum when collisions are included must be zero
 in the case of steady state current flow

- Find the total rate of momentum change from collisions:
 ↳ If collisions are truly random, there will be a constant probability of
 collisions at any time for each electron

Consider:

- Group of N_0 electrons at time $t=0$
 where $N(t)$ as the number of electrons that have NOT undergone a collision by time t .
 ↳ constant of probability.
- ∴
$$\left| \frac{-dN(t)}{dt} \right| = \left(\frac{1}{\bar{t}} \right) N(t)$$

 rate of decrease in $N(t)$ is proportional to the number left unscattered at t .

Solution:

$$N(t) = N_0 e^{-t/\bar{t}}$$

where \bar{t} : mean time between scattering events.
 (mean free time).

- The probability that any electron has a collision in the time interval dt is dt/\bar{t}

∴ $dP_x = -P_x \frac{dt}{\bar{t}}$ } differential change in P_x .

•
$$\frac{dP_x}{dt} \Big|_{\text{collisions}} = -\frac{P_x}{\bar{t}}$$
 } due to the decelerating effect of collisions

- The sum of acceleration & deceleration effects must be zero for a steady state

$$\therefore \left| -\frac{P_x}{\bar{t}} - nq E_x \right| = 0$$

\therefore Average momentum per electron is:

$$\boxed{\langle p_x \rangle = \frac{p_x}{n} = -q \bar{t} E_x.} \quad \textcircled{1}$$

\therefore Constant net velocity in the negative x -direction

$$\boxed{\langle v_x \rangle = \frac{\langle p_x \rangle}{m^* n} = \frac{-q \bar{t}}{m^* n} E_x} \quad \textcircled{2}$$

\hookrightarrow Shows the net drift of an average electron in response to the electric field. (drift speed)

③ The drift speed is smaller than the random speed due to thermal motion v_{TH} . (individual electrons move in many directions by thermal motion, during a time period).

• The current density:

$$\boxed{J_x = -q n \langle v_x \rangle} \quad \textcircled{3}$$

$\left[\frac{\text{Ampere}}{\text{cm}^2} = \frac{\text{coulomb}}{\text{electron}} \cdot \frac{\text{electron}}{\text{cm}^3} \cdot \frac{\text{cm}}{\text{s}} \right]$

\hookrightarrow Number of electrons crossing a unit area per unit time ($n \langle v_x \rangle$) multiplied by the charge of electron ($-q$)

(sub ② into ③)

\therefore Average velocity:

$$J_x = \frac{n q \bar{t}}{m^* n} E_x$$

\therefore Current density is proportional to the electric field as expected.

from Ohm's law:

$$\boxed{J_x = \sigma E_x} \quad \text{where } \sigma = \frac{n q \bar{t}}{m^* n}$$

& conductivity $\sigma (\Omega^{-1} \text{-cm})^{-1}$ can be written as:

$$\boxed{\sigma = q n \mu n} \quad \text{where } \mu = \frac{q \bar{t}}{m^* n}$$

- μ_n is the electron mobility. describes the ease with which electrons drift in the material.
- m_n^* is the conductivity effective mass for electrons which is different from the density-of-states-effective mass. } used for charge transport problems

$$\therefore \frac{1}{m_n^*} = \frac{1}{3} \left(\frac{1}{m_e} + \frac{2}{m_t} \right)$$

(eg) - - - - -

Calculate the conductivity effective mass of electron in Si

$$Si \Rightarrow m_e = 0.98 m_0$$

$$m_t = 0.19 m_0$$

$$\therefore \frac{1}{m_n^*} = \frac{1}{3} \left(\frac{1}{m_e} + \frac{1}{m_y} + \frac{1}{m_z} \right) = \frac{1}{3} \left(\frac{1}{m_e} + \frac{2}{m_t} \right)$$

$$\frac{1}{m_n^*} = \frac{1}{3} \left(\frac{1}{0.98 m_0} + \frac{2}{0.19 m_0} \right)$$

$$m_n^* = 0.26 m_0$$

Mobility can also be expressed by:

$$\mu_n = \odot \frac{\langle v_x \rangle}{E_x} \quad \left. \begin{array}{l} \text{average particle drift velocity per unit} \\ \text{electric field} \end{array} \right\}$$

$\left[\text{cm/s} \right]$ results in a positive value of mobility, since electrons drift opposite to the electric field.
 $\left[\text{V/cm} \right]$

\therefore Current density can be written in terms of mobility:

$$\boxed{J_x = q n \mu_n E_x}$$

(Derivation has been based on the assumption that the current is carried primarily by electrons).

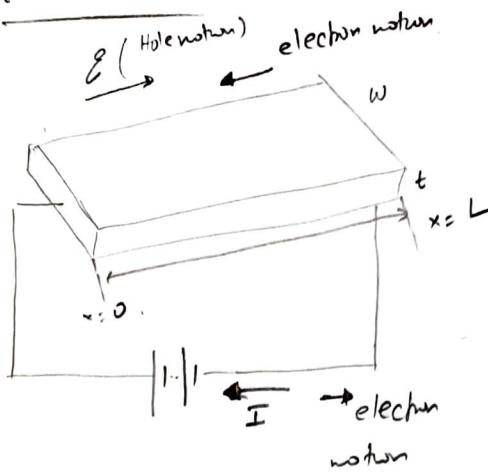
\rightarrow For holes

$$J_x = +q p \mu_p E_x \quad \therefore \mu_p = \frac{+eV_x}{E_x}$$

\therefore Both together:

$$\boxed{J_x = q (n \mu_n + p \mu_p) E_x = \sigma E_x}$$

• Drift & Resistance



$$\cdot R = \frac{\rho l}{A} \Rightarrow R = \frac{eL}{wt} = \frac{L}{wt} \times \frac{1}{\sigma} \quad " "$$

• Mechanism of carrier drift requires holes to move as a group in the direction of the electric field (E) & electrons to move as a group in the opposite direction of the electric field (E).

• Conventional current is +ve in the hole flow direction
-ve in the electron flow direction

\therefore Drift current is constant throughout the bar.

• For electrons:

\rightarrow For every electron leaving the left end ($x=0$) there is a corresponding electron entering at ($x=L$) \therefore electron concentration remains constant (N).

• For holes:

\rightarrow If hole reaches the ohmic contact at $x=L$ \rightarrow recombines with an electron supplied from the external circuit.

\rightarrow As the hole disappears a corresponding hole must appear at $x=0$, to maintain space charge neutrality.

\rightarrow Reasonable to consider the source of this hole generation as CHP.
 \rightarrow Reasonable to consider the source of this hole generation as CHP.
at $x=0$), with the hole flowing into the bar & the electrons flowing into the external circuit.

- Effects of Temperature & Doping on Mobility
- Scattering Mechanisms that influence electron & hole mobility
 - lattice scattering
 - Impurity scattering

Lattice scattering, a carrier moving through the crystal is scattered by a vibration of the lattice, resulting from the temperature.

(Vibration of atoms in the crystal are called phonons.)

∴ lattice scattering is also known as phonon scattering.

⇒ Frequency of scattering events increases as temperature increases, since the thermal agitation of lattice becomes greater. ∴ [mobility decreases]

• Impurity scattering

→ Scattering caused by crystal defects (such as ionized impurities) become dominant at low temperatures.

Since atoms in lattice are cooler ∵ less agitated, lattice scattering is less important.

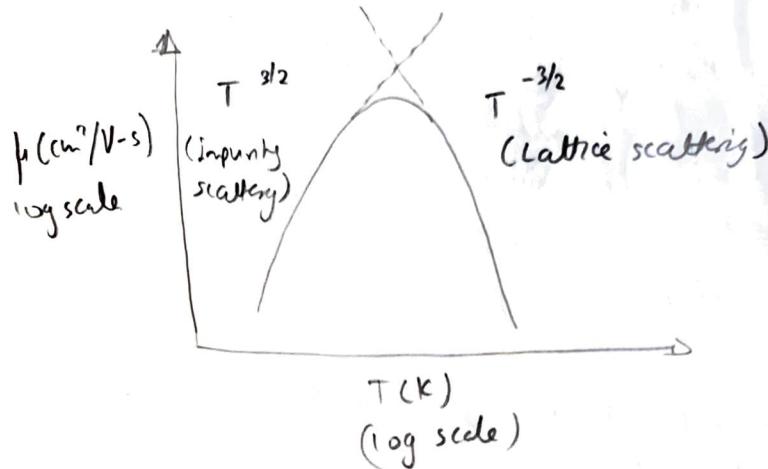
The thermal motion of the carriers is also slower.

Since slowly moving carrier is likely to be scattered more strongly by an interaction with a charged ion than a carrier with greater momentum → impurity scattering cause a decrease in mobility as temperature decreases.

• Accurately to equation:

$$dP_x = -P_x \frac{dt}{\tau} \quad \therefore P_x \propto \frac{1}{t}$$

Since scattering probability is inversely proportional to the mean free-time
⇒ mobility inversely proportional to



→ Total mobility:

$$\hookrightarrow \frac{1}{\mu_T} = \frac{1}{\mu_1} + \frac{1}{\mu_2} + \dots$$

∴ the mechanism causing the lowest mobility dominate.

Example: ①

A Si bar of 0.1 cm long and $100 \mu\text{m}^2$ area is doped with 10^{17} cm^{-3} phosphorus.
Find the current at 300 K with 10 V applied

→ Since voltage applied is only 10 V ∴ electric field is weak.
∴ ohmic regime. ($\mu_n = 700 \text{ cm}^2/\text{Vs}$)

$$\sigma = \mu_n q n_0 = 700 \times 1.6 \times 10^{-19} \times 10^{17} = 11.2 (\Omega \cdot \text{cm})^{-1} = \rho^{-1}$$

$$\rho = 0.0893 \Omega \cdot \text{cm}$$

$$R = \frac{\rho l}{A} = 0.0893 \times 0.1 \times 10^{-6} = 8.93 \times 10^3 \Omega$$

$$I = V/R = \frac{10}{(8.93 \times 10^3)} = 1.12 \text{ mA}$$

High - Field Effects

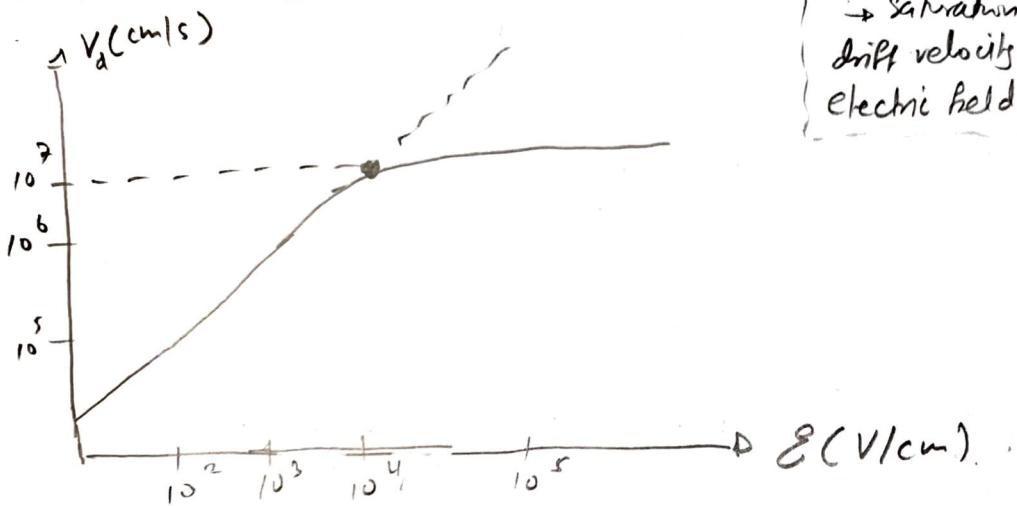
$$\sigma = \frac{nq^2t}{m^2}$$

For now we assumed that Ohm's law was valid. [$J_x = \sigma E_x$]
 LD Assumed that :

- Drift current is proportional to electric field.
- The proportionality constant (σ) is not a function of E .

HOWEVER :

For large electric fields ($> 10^3 \text{ V/cm}$) can cause drift velocity v_d to exhibit dependence on E .
 ∴ Therefore the current $I = q n v_d$ to exhibit dependence on E .
 LD This dependence of σ upon E is an example of a hot carrier effect → carrier drift velocity (v_d) is comparable to the thermal velocity (v_{th})



→ saturation of electron drift velocity at high electric field for Si

Upper limit is reached for the carrier drift velocity in a high field.
 LD This limit occurs near the mean thermal velocity. ($\approx 10^7 \text{ cm/s}$).
 & represents the point at which added energy imparted by the field is transferred to the lattice rather than increasing the carrier velocity.

⇒ Result of this scattering limited velocity is fairly constant current at high field.

Hall Effect

- A magnetic field is applied perpendicular to the direction in which holes drift in a p-type bar \rightarrow the path of the holes tend to be deflected.
- \rightarrow Using vector notation, the total force on a single hole due to the electric and magnetic field is:

$$F = q(E + v \times B) \quad (\text{to cross product})$$

In y-direction.

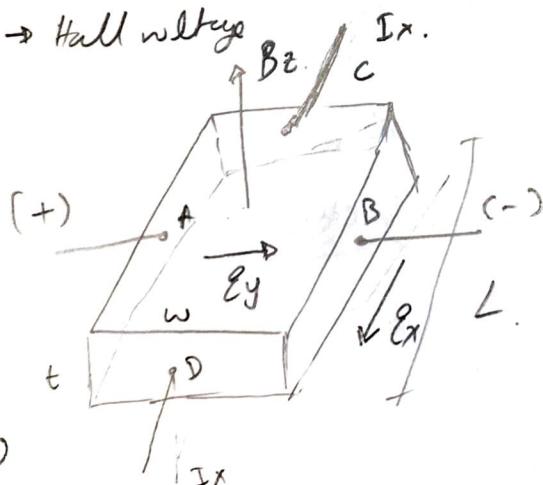
$$F_y = q(E_y - v_x B_z).$$

\rightarrow Result, unless an electric field (E_y) is established along the width of the bar, each hole will experience a net force ("acceleration") in the $-y$ -direction due to the $q v_x B_z$ product.
 \therefore To maintain a steady state flow of holes, no electric field (E_y) must be balanced by the product $v_x B_z$:

$$E_y = v_x B_z$$

$$\therefore F_y = 0$$

$$\therefore V_{AB} = E_y w \rightarrow \text{Hall voltage}$$



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Figure ①

$$\therefore E_y = \frac{J_x B_z}{q \rho_0} = R_H J_x B_z, \quad R_H = \frac{1}{q \rho_0}$$

• Thus Hall field is proportional to the product of the current density & the magnetic flux density.

$$R_H = \frac{1}{qP_0} \rightarrow \text{Hall coefficient}$$

$$\rightarrow P = \frac{R_{Ht}}{L} = \frac{V_{CD}/J_x}{L/wt}$$

$$(\Rightarrow) \mu_P = \frac{\sigma}{qP_0} = \frac{1/C}{q(1/q R_H)} = \frac{R_H}{C}$$

→ Measurement of the Hall coefficient and the resistivity over a range of temperature yields a plot of majority carrier concentration & mobility vs temperature. [holes]

[electrons] $\rightarrow (-q)$; $-V_{AB}$ (Hall voltage); $-R_H$ (Hall coeff).

(\Rightarrow) Sign of the Hall Voltage is common technique to determine if a sample is p-type or n-type

(eg) Figure ①, $w = 0.1\text{mm}$, $t = 10\mu\text{m}$, $L = 5\text{mm}$.

$B = 10\text{ kG}$ in the direction shown ($1\text{kG} = 10^{-3}\text{ Wb/cm}^2$)

$$I = 1\text{mA}$$

$$V_{AB} = -2\text{mV}$$

$$V_{CD} = 100\text{mV}$$

$$\rightarrow B_z = 10^{-4}\text{ Wb/cm}^2$$

• From the sign of V_{AB} \rightarrow majority carriers are electrons.

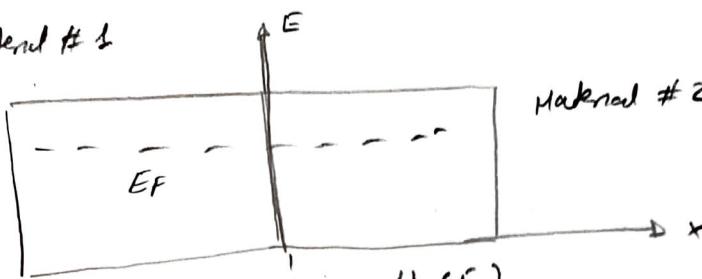
$$n_0 = \frac{I z B_z}{q + (V_{AB})} = \frac{(10^{-3})(10^{-4})}{(1.6 \times 10^{-19})(2 \times 10^{-3})(10^{-3})} = 3.125 \times 10^{17} \text{ cm}^{-3}$$

$$P = \frac{R}{L/wt} = \frac{V_{CD}/J_x}{L/wt} = \frac{0.1/\omega^{-3}}{0.5/0.01 \times \omega^{-3}} = 0.002 \text{ S cm}$$

$$\mu_n = \frac{1}{P q n_0} = \frac{1}{(0.002)(1.6 \times 10^{-19})(3.125 \times 10^{17})} = 10.000 \text{ cm}^2(\text{V.s})^{-1}$$

Invariance of the Fermi-Level Equilibrium

Material #1



Density of states: $N_1(E)$

Fermi-Distribution: $f_1(E)$

$N_2(E)$

$f_2(E)$

\Rightarrow No net energy transfer, no net charge transport, no current at thermal equilibrium.

\rightarrow For any transfer of electrons from Material 1 \rightarrow 2 must be exactly balanced by the opposite transfer of electron from 2 \rightarrow 1.

\therefore At energy E the rate of transfer of electrons from 1 \rightarrow 2 is proportional to the number of filled states at E in material 1. Likewise to the number of empty states at E in material 2.

$$\text{rate from 1 to 2} \propto N_1(E) f_2(E) \cdot N_2(E) [1 - f_2(E)] \quad (*)$$

where: $f(E) \rightarrow$ probability of states being filled at E .

$$\text{rate from 2 to 1} \propto N_2(E) f_1(E) \cdot N_1(E) [1 - f_1(E)] \quad (**)$$

At equilibrium rates must be equal:

$$(=) N_2 f_2 N_2 - N_2 f_1 N_2 = N_2 f_2 N_1 - N_2 f_2 N_1 f_1$$

which results in:

$$f_1(E) = f_2(E) \text{ that is } [1 - e^{(E-E_F1)/kT}]^{-1} = [1 + e^{(E-E_F2)/kT}]^{-1}$$

conclude that $E_{F1} = E_{F2} (=)$ No discontinuity in the equilibrium Fermi Level.

Fermi level at equilibrium must be constant throughout materials in intimate contact \therefore no gradient exist. $\rightarrow \frac{dE_F}{dx} = 0$

Chapter 4 - Excess Carriers in Semiconductors

- Excess carriers can be created:
 - optical excitation e.g. laser, light, sunlight
 - electron bombardment
 - injected across a forward-biased pn-junction.

Quasi-Fermi levels:

In summary the quasi-Fermi levels F_n & F_p are steady state analogues of the equilibrium Fermi level E_F .

- When excess carriers are present, the deviations of F_n & F_p from E_F indicate how far the electron & hole populations are from the equilibrium value n_0 & p_0 .

The separation of the quasi-Fermi levels F_n & F_p is a direct measure of the deviation from equilibrium ($F_n = F_p = E_F$).

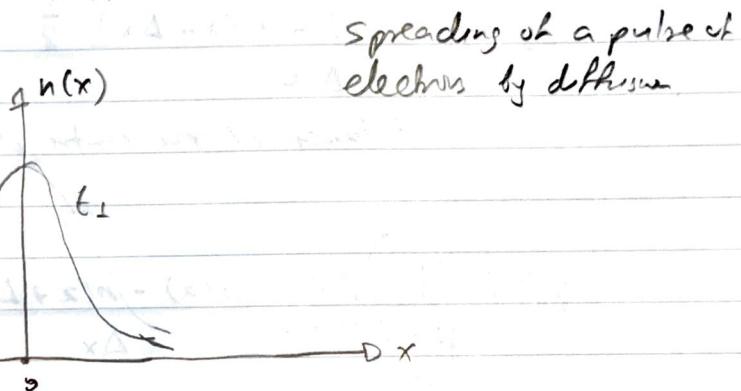
Useful in visualizing minority & majority carrier concentrations in devices where these quantities vary in position.

Diffusion of Carriers

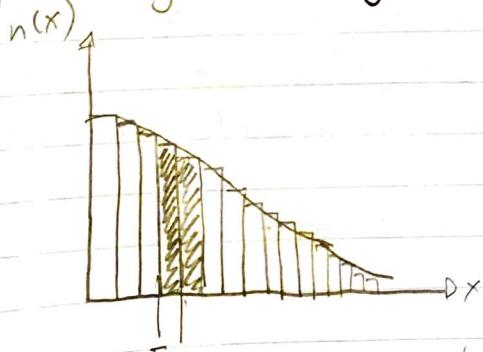
- When excess carriers are created non-uniformly in a semiconductor, the electron & hole concentration vary with position in sample
- ④ Variation (gradient) in $n \& p \rightarrow$ net motion of the carriers from regions of high concentration to regions of low concentration \Rightarrow diffusion.

Diffusion Process

- ↳ random motion of the individual molecules.
- Carriers in a semiconductor diffuse in a carrier gradient by random thermal motion & scattering from the lattice & impurities.

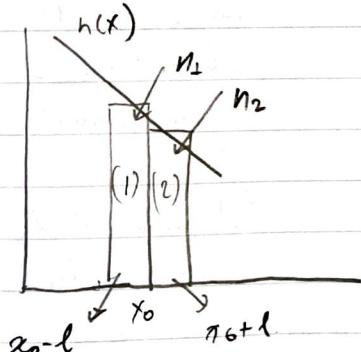


\rightarrow Rate at which the electrons diffuse is a one-dimensional problem. By considering an arbitrary distribution $n(x)$



(mean free path)
such incipient distance

(=)



④ (=) Electron in segment (1) has equal chances moving left & right & in mean free time (T) half of them will move into segment #2.

- Same is true for the other side also

\therefore Net number of electrons passing x_0 from left to right
in a mean time is

$$\frac{1}{2} (n_1 \bar{l} A) - \frac{1}{2} (n_2 \bar{l} A) \quad \text{where } A \Rightarrow \text{area perpendicular to } x.$$

$$\therefore \phi_n(x_0) = \frac{\bar{l}}{2t} (n_1 - n_2) \Rightarrow \begin{aligned} &\text{rate of electron flow is +ve} \\ &x \text{ direction per unit Area} \\ &[\text{electron flux density}] \end{aligned}$$

Since no mean free path \bar{l} is small difference in electron concentration ($n_1 - n_2$) can be written as

$$n_1 - n_2 = \frac{n(x) - n(x + \Delta x)}{\Delta x} \bar{l}$$

where x is taken at the centre of segment (\perp) & $\Delta x = \bar{l}$.

$$\phi_n'(x) = \left(\frac{\bar{l}^2}{2t} \right) \lim_{\Delta x \rightarrow 0} \frac{n(x) - n(x + \Delta x)}{\Delta x} = \frac{\bar{l}^2}{2t} \frac{dn(x)}{dx}$$

called electron diffusion coefficient [D_n] [cm^2/s]

- (-) arises from the definition of the derivative
↳ indicates that the net motion of electrons due to diffusion is in the direction of decreasing electron concentration [moving from high concentration to low concentration]

- Q. Show that hole in the hole concentration gradient move with a diffusion coefficient D_p .

?

$$\phi_h(x) = -D_h \frac{dn(x)}{dx}$$

$$\phi_p(x) = -D_p \frac{dp(x)}{dx}$$

- The diffusion current crossing a unit area (current density) is the particle flux density multiplied by the charge of carrier.

$$J_n(\text{diff}) = -(-q) D_n \frac{dn(x)}{dx} = +q D_n \frac{dn(x)}{dx}$$

$$J_p(\text{diff}) = -(+q) D_p \frac{dp(x)}{dx} = -q D_p \frac{dp(x)}{dx}$$

\Rightarrow Note: Electrons & holes move in a carrier gradient but resulting currents are in opposite directions because of the opposite charges of electron & holes.

Net minority charge carriers can contribute significantly to the current through diffusion

in an n-type material moving back in combination with an n-type carrier of magnitude n_p (the carrier density)

in the opposite gradient

Diffusion and Drift Currents; Built-in Fields

- If an electric field is present in addition to carrier gradient, current densities will have:
 - drift component
 - diffusion component.

$$J_n(x) = q \mu_n n(x) E(x) + q D_n \frac{dn(x)}{dx}$$

drift

diffusion

$$J_p(x) = q \mu_p p(x) E(x) - q D_p \frac{dp(x)}{dx}$$

- Total current density:

$$J(x) = J_n(x) + J_p(x)$$

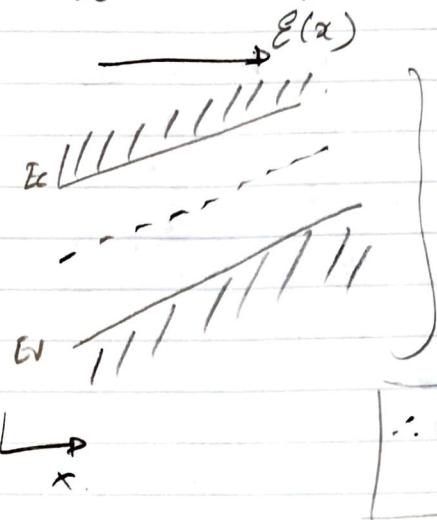
Note: Minority charge carriers can contribute significantly to the current through diffusion.

(eg)

in an n-type material minority hole concentration (p) may be many orders of magnitude smaller than electron concentration (n).

but $\rightarrow \frac{dp}{dx}$ may be significant

- Energy band diagram of semiconductor in an electric field



④ Since electron's drift in the direction opposite to $E(x)$
we expect potential energy to increase
in the direction of the field.

$$E(x) = -\frac{d(Vx)}{dx} \quad | \quad V(x) = \frac{Ex}{-q}$$

$$\therefore E(x) = -\frac{dV(x)}{dx} = -\frac{d}{dx} \left[\frac{Ex}{-q} \right] = \frac{1}{q} \frac{dEx}{dx} //$$

- ④ At equilibrium:

$$E(x) = \frac{D_p}{\mu_p} \perp \frac{dp(x)}{dx}$$

$$E(x) = \frac{D_p}{\mu_p} \perp \left(\frac{dE_i}{dx} - \frac{dE_F}{dx} \right)$$

$$\therefore \boxed{\frac{D}{q} = \frac{kT}{q}} \quad \} \quad \text{Einstein relation}$$